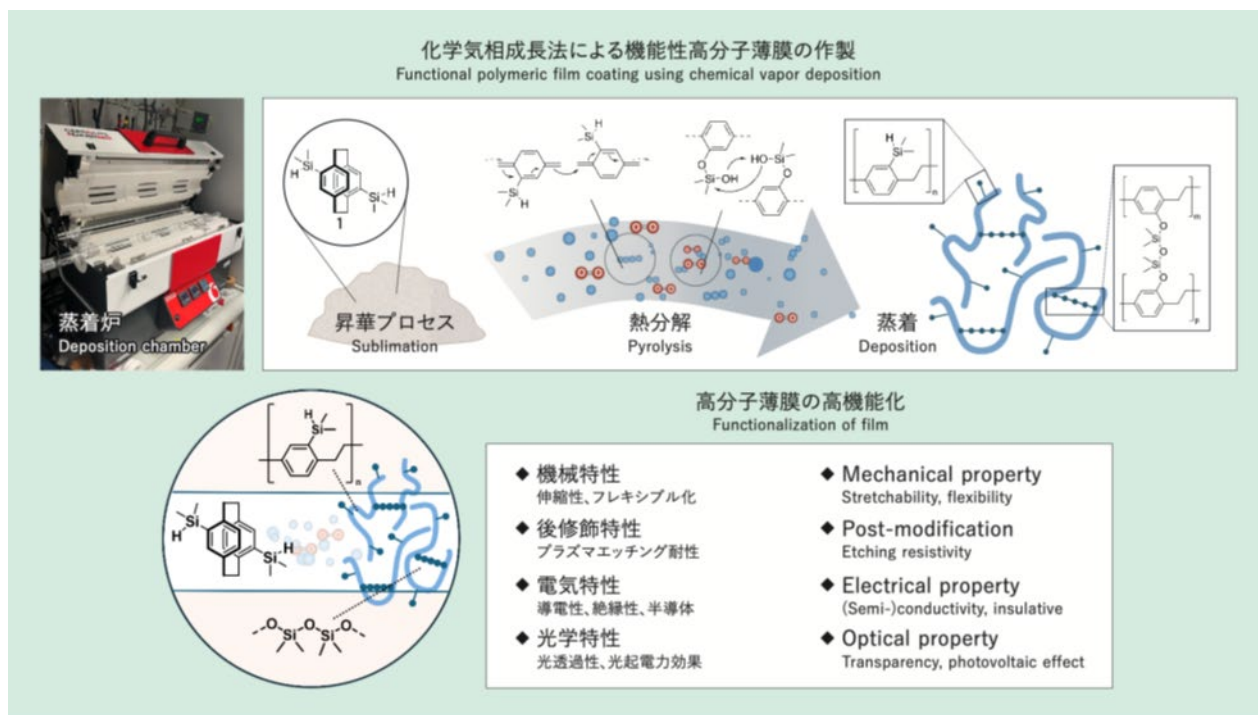


## High-performance polymer thin films for Med & Semiconductor coating New functional thin films for Med & Semi

### Background and Technical Challenges

Chemical vapor deposition enables conformal thin-film coating at room temperature. However, film formation without loss of material function is hampered by molecular instability from heat or pressure changes.



### R&D Goals and Outcomes

CVD enables polymer thin-film with biocompatibility, transparency & conductivity for durable device coating.

### Key Technologies

#### 01 Core Technologies

We developed a sublimation method preserving functions of synthesized materials, enabling defect-minimized, damage-free thin-film deposition.

#### 02 Key Differentiators

Our method enables the synthesis of functional CVD films with optimal thickness control, fewer pinholes, and higher adhesion forces compared to conventional coating processes.

**Use Cases** Environmental Services

**R&D phase** Research

**Technology Schedule** FY27-29

**Commercialization Schedule** After FY30

**【Exhibitors】**  
NTT Research, Inc. MEI Lab.

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[NTT Research, Inc.](#)

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Technische Universität München

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